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Enhanced high-order harmonic generation driven by a wave-front corrected high-energy laser

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Abstract

We developed and implemented an experimental setup for the generation of high-energy high-order harmonics in argon gas for nonlinear experiments in the XUV spectral range. High-order harmonics were generated by loosely focusing a high-energy laser pulse centered around 800 nm into a gas cell filled with argon in a phase-matching condition. The wavefront distortions of the driving pulse were corrected by a deformable mirror, and the XUV conversion efficiency was significantly improved due to the excellent beam profile at focus. A high-damage-threshold beam splitter was used to eliminate high-energy driving pulses copropagating with high-order harmonics. The setup has a potential to provide intense ultrashort XUV pulses reaching the intensity levels required for nonlinear experiments in the XUV spectral range.

Introduction

High-order harmonics (HH) generated by the interaction of an ultrafast high power laser with atoms and molecules is recognized as a very attractive coherent short-wavelength light source [1]. HH has been applied to many research areas such as attosecond science, plasma physics, high-resolution imaging, spectroscopy and nonlinear optics in the extreme ultraviolet (XUV) region [2].

Currently, the energy of XUV pulses available is limited by the low conversion efficiency and the energy of the driving laser. For the further development of a variety of applications, one of the most important issues is XUV pulse energy scaling [3]. Rudawski *et al* have generated 200 nJ per pulse and per harmonic order in argon [4]. A number of groups [5-7] have generated μ -level harmonic energy in the XUV region in pulse trains. The increase of harmonic energy is linearly dependent on the focusing area of the driving pulse. This energy scaling method can be universally applied to HH in neutral gases. A loosely focused beam with an excellent beam quality is required for the phase-matching condition in a long interaction length.

Unfortunately, in Chirped Pulse Amplification (CPA) laser systems with joule-level pulse energies, geometrical aberrations and surface quality from optical components, thermal effects and inhomogeneous doping in Ti:Sapphire crystals affect the beam profile and focusability, degrading the energy distribution and wavefront [8]. A large portion of the pulse energy will be spread out into the wings of the focal spot.

Another challenge is the separation of the high-intensity pump pulse from the co-propagating harmonics. It is necessary to attenuate the intensity of the pump pulses to less than ten millijoules per square centimeter to avoid damaging the XUV optics or samples placed in the beam. Nagata *et al* reported a beam splitter (BS) for wavelengths shorter than 30 nm, which

used a 10 nm thick niobium nitrogen (N_bN) film prepared on a Si substrate [9]. However, the low damage threshold of Si restricted the pump laser to the level of hundreds of millijoules/cm².

In this study, we present progress towards finding the solutions to these two challenges.

Experimental setup, Results and Discussions

Figure 1 illustrates the HH generation setup, which consists of four sections: the laser system [10], HH generation, experimental pump-probe station, and diagnostics. The sections are connected by vacuum tubes and chambers.

The experimental studies were carried out using a three-stage 10-Hz Ti:Sapphire CPA laser system pumped by flash-lamp-pumped Nd:YAG lasers. The system produces an output of 1 J pulse energy with a center wavelength at 800 nm, a pulse duration of 35 fs, and a beam diameter of 30 cm.

Deformable mirror (DM) has been applied to a low-energy Ti:Sapphire laser to optimize highorder harmonics [11-14]. In this paper, we used a DM to correct the wavefront (WF) of a Ti:Sapphire laser at the joule energy level to improve the beam profile at the focal point and thus increase the effective interaction intensity. In addition, we designed a high-reflectivity, high-damage-threshold BS for wavelengths shorter than 50 nm. The absolute energy of HH was measured directly with an unbiased silicon XUV photodiode, and the XUV spectrum was recorded by a calibrated XUV charge-coupled device (CCD) camera.

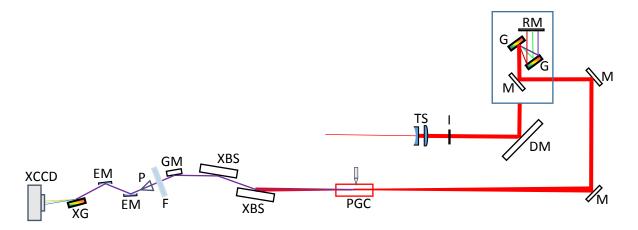


FIG. 1. Experimental setup with a f=25 m focusing configuration: TS - telescope, I - iris, DM - deformable mirror, M - folding mirror, G - grating, RM - roof mirror, PGC - pulsed gas cell, XBS - XUV beam splitter, GM - gold mirror, F - aluminum filter, P - XUV photodiode, EM - ellipsoidal mirror, XG - XUV grating, XCCD - XUV CCD camera.

The driving pulse was loosely focused by a telescope, which includes one plano-concave lens and one plano-convex lens with a focal length of 600 mm and -1600 mm, respectively. By varying the separation of the two lenses, a tunable focal length can be achieved. This is of great importance for the control of the beam size, which allows for re-adjustment of the focusing geometry as well as the intensity distribution at the focus and thus allows us to optimize the phase-matching condition and increase the XUV pulse energy in a simple way. An f=25 m loose focusing geometry in the HH generation cell was employed in our HH setup. The pump beam size was increased to 68 mm before the compressor by a telescope to avoid damaging the optical components. The WF of the pump pulse was corrected by a deformable mirror [15]. The WF distribution of the pump pulse was measured with a Shack-Hartman sensor. The measurement results are used to feedback control the deformable mirror to correct the driving laser WF distortions. The Root Mean Square (RMS) of the WF distribution was reduced from 600 nm to 25 nm, corresponding to a value of $\lambda/32$, where λ is the center wavelength of the driving pulse. The effects of the WF distortions on the beam profile at focus are shown in Figure 2.

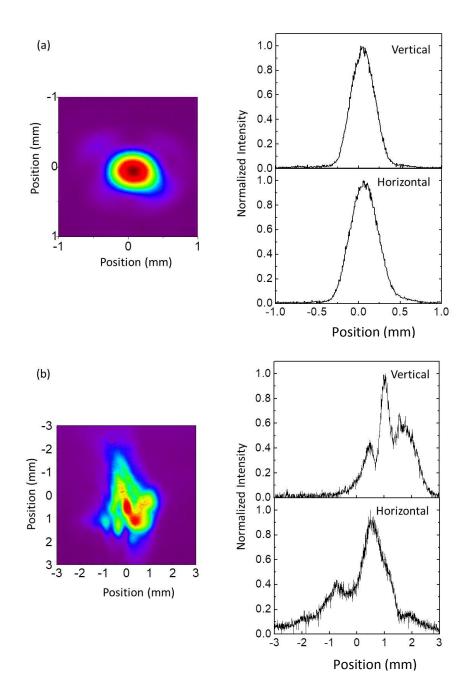


FIG. 2. Driving pulse beam profile at focus with (a) and without (b) wave-front correction.

Nearly a diffraction-limited beam with a diameter of 650 μ m (full width at half maximum of the intensity) was obtained after the correction, which increased the effective intensity at the focal point by one order of magnitude.

In the generation chamber, the interaction gas cell has a diameter of 4.6 mm and a length of 100 mm. The diameter of the holes in the cell is about 0.8 mm. The gas was released at a repetition rate of 10 Hz controlled by a valve driven by a piezo-electric actuator and synchronized with the laser pulse. The valve can provide sufficient gas inside the gas cell allowing good phase matching. To maximize the HH signal, we optimized the opening time of the valve. The HH beam and the driving laser beam propagate collinearly to the XUV BS chamber.

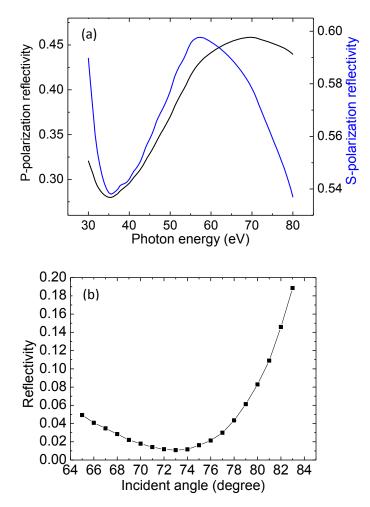


FIG. 3. (a) Calculated reflectivity for XUV BS as a function of the XUV photon energy for both s-(blue) and p-polarization (black) at an incident angle of 73°, (b) Measured IR reflectivity of XUV BS as a function of the incident angles for the p-polarized driving pulses.

A designed XUV BS was used to transmit the fundamental laser and reflect XUV. Tantalum pentoxide (Ta_2O_5) is a high-quality thin film material that can be deposited on a fused silica (SiO₂) substrate by sputtering. The BS was coated with 5 layers of SiO₂/ Ta_2O_5 films, which has a low

attenuation ratio and a high damage-threshold intensity of at least 100 TW/cm² for the 35 fs driving pulses. The reflectivity for the XUV light was calculated from the complex refractive indices of the Ta₂O₅ film and fused silica [16]. Figure 3 (a) shows the calculated reflectivity of Ta₂O₅ film deposited on SiO₂ substrates as a function of the wavelength for both s- and p-polarized HH. The experimental results show that the actual reflectivity is smaller than the calculated one because of the roughness on the coating surface [16]. Reflectivity of the 35 fs, 800 nm, p-polarized pump pulses was measured as a function of incident angle presented in Figure 3 (b). The minimum reflectivity was 1%, which was achieved at an incident angle of 73° for the p polarization, while it is ~78% for the s polarization The two BSs were placed orthogonally to attenuate both s- and p-polarized driving laser to facilitate the gating technique for the isolated attosecond pulses in near future [17]. Afterwards, a 200 nm thick aluminium (AI) filter is used to completely remove the fundamental beam.

The absolute energy of the HH was measured directly with a silicon XUV photodiode (AXUV 100), which covers a wide spectral range. The quantum efficiency and sensitivity are given in Ref. [18]. The signal from the detector was recorded by a oscilloscope. The measured XUV pulse energy corresponds to an estimated pulse energy of 0.3μ at the exit of the gas cell, assuming a total 1% throughput for the two XUV separators, a gold mirror and a 200 nm Al filter with oxidation layers [19].

Two ellipsoidal mirrors coated with gold were placed in the experimental chamber to tightly focus the XUV beam to a diameter of 8 μ m. The ellipsoidal mirrors imaged the XUV beam into an XUV spectrometer located in the diagnostics chamber. A grazing incidence, aberration corrected concave grating (Hitachi 001-0640 XUV) was used to disperse the XUV spectra to an XUV CCD camera. The following parameters were carefully controlled in order to achieve the best phasematching condition: fundamental pulse energy, gas pressure, gas cell position relative to the laser focus, focus beam profile and size. The dependence of the total harmonics generated in argon as a function of the gas pressure and pump pulse energy after the wavefront correction is shown in Figure 4. We recorded a set of HH spectra while varying the gas pressure. The signal is normalized to the maximum obtained for total harmonics. The gas pressure in the cell is adjusted by controlling the backing pressure applied to the nozzle.

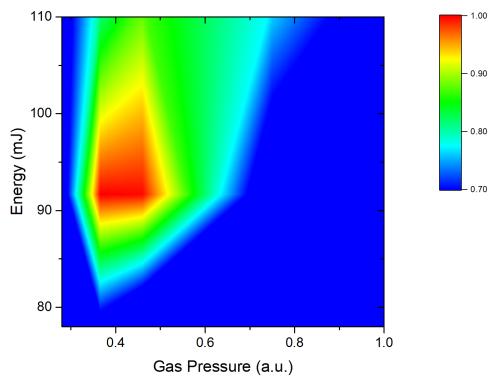


FIG. 4. Intensity of the total harmonics generated in argon as a function of the generation gas pressure and driving laser energy.

Figure 5 shows the typical harmonic spectra for two different driving laser wavefront distortions in argon under the phase-matching condition. The RMS of the wavefron distortion was measured to be 50 nm and 230 nm, respectively, with and without the deformable mirror. The phase-matching condition was optimized for the total energy yield of HH. Low-orders (<21st) are strongly absorbed in argon gas [3]. The input laser energy and medium length were 90 mJ and 100 mm, respectively. With a better WF correction, the harmonic signal was enhanced by more than 9 times and the conversion efficiency was improved by a factor of 18. With a larger f number (f=75 m), the full pulse energy (1 J) can be applied to boost the XUV pulse energy by more than one order of magnitude.

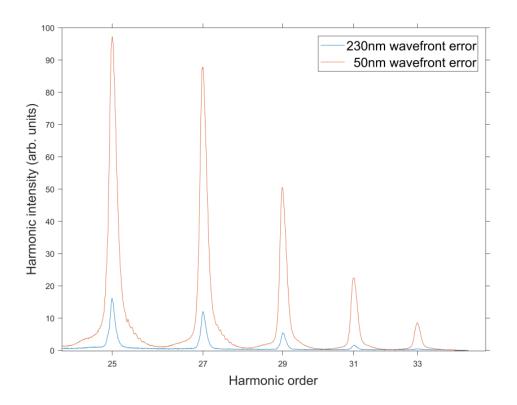
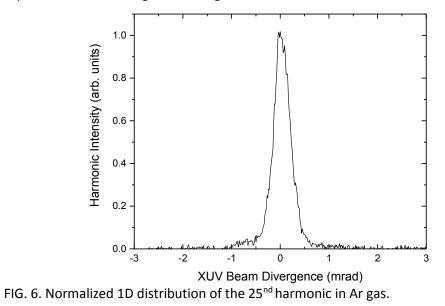


FIG. 5. Experimental harmonic spectra in Ar gas driven by pump lasers with 50 nm wavefront error corrected by a DM and with 230 nm wavefront error without wavefront correction. Figure 6 depicts the far-field spatial profile of the 25^{th} harmonic. The profiles were integrated with respect to wavelength. The output beam divergence was estimated to be ~ 0.4 mrad (FWHM) compared with the driving laser divergence of ~ 1.5 mrad



Conclusions

In summary, we have developed a high-energy HH setup and generated a total energy of 0.3 μ HH per laser pulse in argon by a loose focusing geometry. The beam quality of the focused highenergy laser pulse was significantly improved by correcting WF distortions using a deformable mirror, resulting in an improvement of the XUV conversion efficiency. We produced an XUV BS with a high-damage-threshold of 100 TW/cm². The XUV source is designed for future studies of nonlinear processes in the XUV spectral range and the attosecond pump-probe experiment. The estimated XUV intensity at focus is ~10¹⁴ W/cm², which is sufficient to induce nonlinear optical phenomena in the XUV region such as the multiphoton ionization processes and the abovethreshold ionization of He or two-photon double ionization of neon [20-22].The conversion efficiency can be held constant when changing the focal length, if the gas pressure, the laser pulse energy, and the medium length are scaled appropriately. By applying this scaling procedure, the harmonic pulse with energy as high as tens of μ could be reached using a loose focusing geometry of *f*=100 m with joule level pump laser. The true attosecond-pump attosecond-probe experiments can be conducted with such a high attosecond pulse energy [23, 24].

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